

Optional module for the automatic, chemical cleaning of flow cell and photometer. To use conjointly with the AMI Codes-II, AMI Codes-II CC, AMI Codes-II TC, AMI Phosphate-II, AMI Phosphate HL or AMI SAC254 monitoring systems.

## Cleaning Module-II

### Ensuring highest accuracy of measurement:

- Chemical cleaning is achieved with periodical additions of one or two cleaning solutions, e.g. 2.5% hypochlorite solution (Javel water) and/or diluted sulfuric acid (2.5%).
- Counteracts bio-growth inside the flow cell and photometer and thereby ensures reliable measured values.
- Factory tested and ready for installation.

### User-friendly operation:

- automatic level monitoring of the reagents.
- Cleaning interval is controlled by the AMI transmitter and can be programmed individually.
- During the cleaning process the AMI transmitter stays in hold mode.

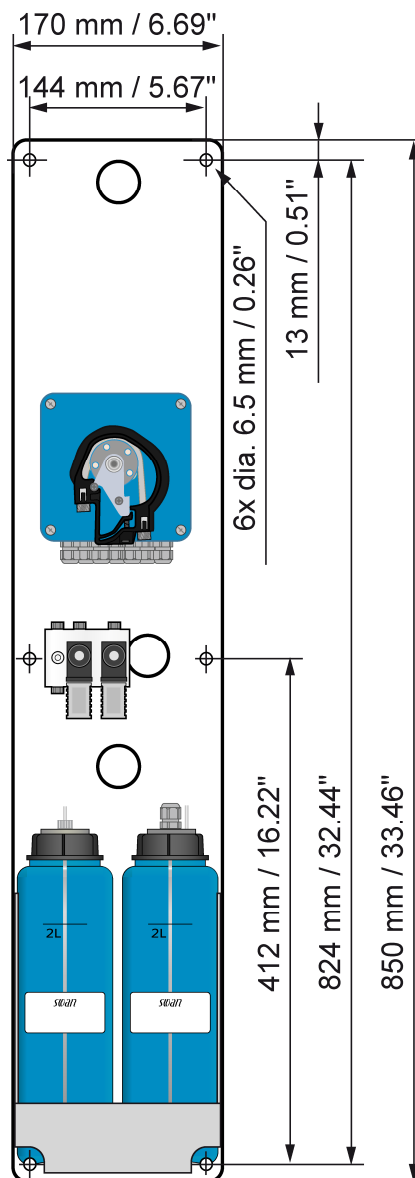
### Scope of delivery:

- Complete system installed on mounting panel including control electronics, reagent dosing system with switching valves, reagent containers and a sensor for level monitoring of the reagents.

### Technical data:

- Panel made of PVC  
Dimensions: 170 x 850 x 200 mm

- Power supply via AMI transmitter.



Cleaning Module-II

<b>Order no.</b>	<b>Cleaning Module-II</b>	<b>A - 8 2 . 3 1 2 . 0 0 0</b>
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### Accessories:

- A-86.191.042 Tubing set for Cleaning Module-II
- A-86.191.151 Frame with tube 2.29 mm for the PeriClip pump